



Redox-Based Resistive Nanomemristor for Neuromorphic Computing

Guest Editor:

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Message from the Guest Editor

With the advent of the artificial intelligence (AI) era, there has been a surge of interest in neuromorphic devices imitating biological neural systems that are presumed to be the most efficient information processors for conducting cognitive tasks such as image/pattern recognition and future prediction.

Over the decades, various types of neuromorphic nanodevice have been demonstrated. Among them, redox-based resistive memory is one of the most promising candidates in terms of scalability, power consumption, switching speed, and endurance/retention characteristics.

To expedite the development of neuromorphic nanodevices, further research is necessary from materials to systems architecture.

In this Special Issue on redox-based resistive memory in nanoscale for neuromorphic computing, we expect contributions from a broad community of scientists and engineers working on redox-based resistive memory including materials and device fabrication. We also anticipate manuscripts dealing with new understanding and characterization methods regarding conduction mechanisms.





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Message from the Editor-in-Chief

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